**Introduction**

Two-dimensional (2D) materials provide a wide range of basic building blocks with distinct optical and electrical properties, which can modulate electrical bands structures\(^1\)\(^{–}\)\(^14\) and improve optoelectronic properties.\(^9\)\(^{–}\)\(^11\) Furthermore, heterostructures can offer a various playground for investigating basic physical and chemical issues.\(^12\)\(^{–}\)\(^18\) Tin(II) selenide (SnSe), as a member of IVA–VIA group, is a stable and distinctive 2D material consisting of earth abundant elements. In addition, SnSe exhibits some novel properties, especially its high thermoelectric performance with a ZT (figure of merit) value of 2.6 and 2.3 at 923 K along the \(b\) and \(c\) directions, respectively,\(^19\)\(^{–}\)\(^20\) which provides a practical way to solve the global energy demands, together with the negative impacts resulting from the combustion of fossil fuels.\(^21\)

Moreover, SnSe is an attractive binary p-type semiconductor material, with an indirect band gap at 0.90 eV and a direct band gap at 1.30 eV,\(^22\)\(^{–}\)\(^23\) which has a wide range of potential applications in infrared optoelectronic devices and photoelectric detectors.\(^24\)\(^{–}\)\(^27\) However, the onefold bandgap restricts the application fields of SnSe and a heterostructure based on SnSe is needed. Currently, most of heterostructures focus on layered crystals with a similar lattice.\(^28\)\(^{–}\)\(^32\) Tongay reported the chemical vapor deposition and growth dynamics of highly anisotropic 2D lateral heterojunctions between pseudo-1D ReS\(_2\) and isotropic WS\(_2\) for the first time.\(^33\) They found the degree of anisotropy of ReS\(_2\) on WS\(_2\) largely depends on the domain size, which is a significant leap forward for the large-scale nanomanufacturing of anisotropic systems. Furthermore, He et al. epitaxially synthesized lateral NbS\(_2\)–WS\(_2\) heterostructure via
a two-step CVD method and the FET based on the heterostructure possessed a well-defined rectification. Heterostructures made by 2D materials with different structures are rarely investigated today. Hence, hexagonal In\textsubscript{2}Se\textsubscript{3} comes into our sight. In\textsubscript{2}Se\textsubscript{3} is an interesting semiconductor of the A\textsuperscript{II}B\textsuperscript{VI} family with double layers of nonmetal atoms and each unit cell consists of [Se-In-Se-In-Se] sheets stacked together through the Se atoms along the c-axis.\textsuperscript{35-40} Recently, the n-type In\textsubscript{2}Se\textsubscript{3} is becoming one of the promising materials for detecting visible light due to its direct and narrow band gap (1.95 eV) and high absorption coefficient in the visible range.\textsuperscript{34,46}

In this study, by combining orthorhombic SnSe and hexagonal In\textsubscript{2}Se\textsubscript{3}, a new vertical heterostructure was prepared via a simple two-step PVD method. Then, the characteristics of morphology, crystalline phase and microstructure of the vertical heterostructure samples were investigated in detail, and the results showed the orthorhombic SnSe nanolayers randomly grown on the top of the hexagonal In\textsubscript{2}Se\textsubscript{3} film with an exposing (100) plane. The samples possess excellent Raman properties, and Raman intensity mappings further confirm the successful achievement of the SnSe/In\textsubscript{2}Se\textsubscript{3} vertical heterostructures. The photoelectric devices based on the SnSe/In\textsubscript{2}Se\textsubscript{3} vertical heterostructures were directly fabricated. The devices demonstrate a dramatic current increase with lower power laser illumination (70 nA at 30 μW 405 nm laser), high responsivity (R) up to 350 mA/W\textsuperscript{-1} and fast photoresponse with 139 ms. This study creates a new avenue for the realization of novel 2D electronic and optoelectronic devices, and more importantly, develops exciting technologies beyond the reach of the existing materials.

**Experimental section**

**Growth of hexagonal In\textsubscript{2}Se\textsubscript{3} film**

Hexagonal In\textsubscript{2}Se\textsubscript{3} film was prepared on fluorochrome mica substrates via a simple physical vapor deposition (PVD) method. The preparation process occurred in a single temperature zone tube furnace. About 0.1 g In\textsubscript{2}Se\textsubscript{3} (99.999%, Alfa) powder and 1 g Se (99.999%, Alfa) powder were loaded in two Al\textsubscript{2}O\textsubscript{3} boats. Then, the In\textsubscript{2}Se\textsubscript{3} powder was placed at the heating center of a quartz tube furnace and the Se powder was put at the upstream of the tube furnace. Two pieces of newly cleaved mica substrates were positioned at the downstream of the tube furnace around 10 cm away from the In\textsubscript{2}Se\textsubscript{3} precursor. The tube furnace was pumped down first, and then filled with high-purity Ar gas to the chamber pressure of about 10 Torr. Sixty sccm Ar was used for the growth of the In\textsubscript{2}Se\textsubscript{3} film. The temperature of the heating zone increased gradually to 850 °C from room temperature in 35 min and remained for 2 min. After the reaction, the furnace was cooled down to room temperature naturally.

**Synthesis of SnSe/In\textsubscript{2}Se\textsubscript{3} vertical heterostructures**

The SnSe/In\textsubscript{2}Se\textsubscript{3} heterostructures were synthesized by directly depositing SnSe on the pre-fabricated In\textsubscript{2}Se\textsubscript{3} film in a horizontal tube furnace. In the experiment, about 0.1 g SnSe powder (99.999%, Alfa) was kept at the heating center and the mica sheets with In\textsubscript{2}Se\textsubscript{3} film were placed at the downstream of the tube furnace about 8 cm away from the SnSe powder. The tube furnace chamber was evacuated, and then filled with high-purity Ar to atmospheric pressure. The growth temperature was 800 °C and kept for 5 min with a 60 sccm Ar flow. After the growth, the furnace was cooled down to room temperature naturally.

**Characterization**

The morphologies of the hexagonal In\textsubscript{2}Se\textsubscript{3} film and SnSe/In\textsubscript{2}Se\textsubscript{3} vertical heterostructures were investigated using an inverted optical microscope (Nikon Inverted Microscope Eclipse Ti-U with a Nikon Digital Sight) and a Hitachi S-4800 field-emission scanning electron microscope (SEM).

The thickness of the samples was confirmed by an atomic force microscope (AFM) Bruker Multimode 8.

X-ray diffraction (XRD) patterns were obtained by a powder X-ray diffractometer (Bruker D8 Focus) with Cu-K\textalpha radiation (λ = 1.5418 Å).

The microstructure and the elemental composition of the as-grown samples were investigated using a JEOL JEM-2100F field-emission transmission electron microscope (TEM) equipped with an energy dispersive X-ray spectroscopy (EDS).

The Raman properties of the SnSe/In\textsubscript{2}Se\textsubscript{3} vertical heterostructures were identified using a confocal Raman microscope (Renishaw InVia) with a 532 nm laser.

**Device fabrication and measurements**

Photodetectors based on the SnSe/In\textsubscript{2}Se\textsubscript{3} vertical heterostructures and SnSe nanolayers were directly fabricated on the mica substrates. In brief, Au electrodes were deposited on the surface of the as-prepared samples via thermal evaporation using Cu grids as the shadow mask. Then, the devices were annealed at 200 °C for 2 hours in Ar atmosphere to improve the contact between the electrodes and the heterostructures. The Photoresponse property of the device was investigated using a Keithley-4200 SCS semiconductor parameter analyzer and a cryogenic probe station. Four different incident lasers (685 nm, 532 nm, 450 nm and 405 nm) were adopted for the illumination.

**Results and discussion**

The SnSe/In\textsubscript{2}Se\textsubscript{3} vertical heterostructures were synthesised using a simple two-step PVD technology, and the preparation process is displayed in Fig. 1a. The SEM image and optical characteristics in Fig. 1b and S1\textsuperscript{†} confirm the formation of a uniform In\textsubscript{2}Se\textsubscript{3} film on the mica substrate and the thickness of the film was determined to be about 16 nm (Fig. S1b\textsuperscript{†}). In the second growth step, the SnSe nanolayers were found to have grown randomly on the as-grown In\textsubscript{2}Se\textsubscript{3} film (Fig. S1c and d\textsuperscript{†}) and showed a rhombic shape with a side length of about 12 μm and a thickness of 48 nm (Fig. 1c and d). The crystalline phase of the SnSe/In\textsubscript{2}Se\textsubscript{3} heterostructure was then investigated using XRD characterization, as displayed in Fig. 1e. Compared with the reference XRD patterns of In\textsubscript{2}Se\textsubscript{3} (PDF 34-0455) and SnSe
In2Se3, while the weak diffraction peak at 31.08° can be ascribed to the (0001) plane of the hexagonal In2Se3. Other obvious diffraction peaks come from the (0001) planes of the fluorophlogopite mica substrate (Fig. S2†).

The microstructure of the SnSe/In2Se3 vertical heterostructure was also investigated using a transmission electron microscope equipped with EDS as exhibited in Fig. 2. The low-magnification TEM image in Fig. 2a shows a vertical heterostructure composed of SnSe nanoplates and In2Se3 film at the bottom. The atomic ratio of Se, In and Sn is confirmed to be about 4 : 2 : 1 (Fig. 2b), matching well with the stoichiometric ratio of a mixture of SnSe and In2Se3. And cuprum in EDS spectrum is from the copper grid. Fig. 2c and e are the high-resolution TEM (HRTEM) images of SnSe and In2Se3 from the heterostructure sample, respectively. The lattice fringes measured from the HRTEM images (Fig. 2c and e) are about 0.35 nm and 0.31 nm (Fig. S4†), which match well with the (10–10) plane of the hexagonal In2Se3 and the (011) plane of the orthorhombic SnSe, respectively. The corresponding SAED images of In2Se3 and the heterostructure sample are exhibited in Fig. 2d and f. A set of well-arranged diffraction spots confirm the good quality and single crystallinity of the heterostructure.

To study the spatial elemental distribution of the sample, EDS elemental mappings and bright field scanning TEM (STEM) image of the vertical heterostructure were then recorded, as displayed in Fig. 2g–j. It can be obviously seen that the In element has a uniform intensity distribution, while Sn is only distributed around the right region in the bright field STEM image of Fig. 2g, indicating the successful fabrication of the vertical heterostructure based on orthorhombic SnSe and hexagonal In2Se3.

The optical properties of the as-prepared SnSe/In2Se3 vertical heterostructures were studied in detail using Raman spectroscopy. The typical Raman spectra of the In2Se3 film, the SnSe/In2Se3 heterostructure, and SnSe are shown in Fig. 3a. Compared with the Raman spectrum of the single SnSe and In2Se3, it can be clearly seen that the heterostructure possesses three strong peaks at 69 cm⁻¹, 148 cm⁻¹ and 103 cm⁻¹, which can be ascribed to the A_g vibration modes of rhomboic SnSe and the interlayer vibration mode of γ-InSe, respectively. In addition, the Raman intensity mappings of 69 cm⁻¹ and 103 cm⁻¹ modes of the heterostructure were also recorded, as shown in Fig. 3c and d, respectively. It can be observed that the Raman signal of SnSe exists only in the center of the image, while the In2Se3 Raman signal distributes throughout the whole image, which further confirms the successful fabrication of the SnSe/In2Se3 vertical heterostructures.

Furthermore, the optoelectronic property of the SnSe/In2Se3 vertical heterostructure was also investigated. Photodetectors
based on the vertical heterostructure were directly fabricated on the mica substrate and the schematic model is displayed in Fig. 4a. Compared with the properties of the device based on the SnSe nanosheet, the heterostructure possesses a small dark current, about 15 nA, shown in Fig. S7, suggesting that the SnSe/In$_2$Se$_3$ vertical heterostructure is more suitable for light detection. Simultaneously, it can be easily seen that the $I$–$V$ curves show an obvious asymmetric characteristic (Fig. S7†), which indicates the formation of a p–n junction in the SnSe/In$_2$Se$_3$ vertical heterostructure and the forward bias is utilized to learn the photoelectronic properties of the heterostructure. Fig. 4b shows the $I$–$V$ curves of the device in the dark and under different laser illumination with the same laser power. Obviously, the current declines as the laser wavelength increases and the current reaches the maximum of 70 nA under 405 nm laser illumination and 5 V bias (Fig. 4b). The broadband response of the device is attributed to the band gap modulation of SnSe and In$_2$Se$_3$. Next, the 405 nm laser was used to investigate the photoelectronic properties in the follow-up experiments due to the best photoresponse. Fig. 4c shows the $I$–$V$ curves of the device under the 405 nm laser illumination with different powers from 30 µW to 1.5 mW. The linear $I$–$V$ curves imply that ohmic contacts have formed between the Au electrode and the heterostructure. A pronounced increase in the current is observed when the device is illuminated with lower laser power and the photocurrent ($I_{ph} = I_{illumination} - I_{dark}$) exhibits one order of magnitude larger than the dark current when the laser power is 1.5 mW, suggesting a strong photoresponse of the device. In Fig. 4d, the photocurrent as a function of the light intensity was plotted. By fitting the experimental data, it is found that the photocurrent can be expressed by a power law equation $I_{ph} \propto P^{0.7}$, where $P$ is the light intensity, indicating good absorption and response to the incident laser. One critical parameter to estimate the performance of the photodetector is the photoresponsivity ($R$), which can be defined by $R = I_{ph}/P$, where $S$ is the effective illumination area of the photodetector. For our device, the effective illumination area is about 144 µm$^2$ and $R$ is calculated to be 180 mA W$^{-1}$–350 mA W$^{-1}$, which is comparable with other heterostructure photodetectors.

Another important parameter for evaluating the performance of the photodetector is the response time. For revealing the response speed, the time-resolved photo-current curve of the device was investigated as shown in Fig. 4e. Under the laser illumination, the current of the device rises drastically and the photo-current increases three times with 5 V bias and a laser power of about 10 mW cm$^{-2}$. After several circles, the device still exhibited a rapid and stable response to the laser illumination. For further evaluating the response rate, we used a chopper with high frequencies to switch the laser. As shown in Fig. 4f, when the laser illumination is in “on” state, the current increases by more than 90% in 156 ms. Meanwhile, the current declines dramatically by more than 90% in 139 ms when the laser illumination is in “off” state. The good reversibility and stability of the device enable the SnSe/In$_2$Se$_3$ vertical heterostructure to be a good building block for high-performance optoelectronic devices.

**Conclusions**

The vertical heterostructure was built via the combination of orthorhombic SnSe and hexagonal In$_2$Se$_3$, using a simple two-step PVD technology, where SnSe randomly grew on the top of the In$_2$Se$_3$ film. The thicknesses of the two materials were about 48 nm and 16 nm, respectively. The XRD pattern indicates the high crystallinity of the heterostructure, preferentially along the $c$ [100] direction (SnSe) and [0001] direction (In$_2$Se$_3$). The HRTEM and SAED results show that the achieved heterostructure possessed high quality and single crystallinity. Moreover, the Raman studies of the heterostructure well-matched with the characteristic peaks of SnSe and In$_2$Se$_3$ and further confirm the relative spatial positions of the two materials in the heterostructure. Furthermore, a two electrode photoresponse device based on the SnSe/In$_2$Se$_3$ vertical heterostructure was fabricated. The device shows a broadband response and the photocurrent displays one order magnification compared with the dark current with a 1.5 mW incident laser. Meanwhile, the photocurrent intensity of the device dramatically increased with changing the incident laser power and it is well defined as $I_{ph} \propto P^{0.7}$, showing good absorption and response to laser illumination. Moreover, the device possessed a high photoresponsivity of up to 350 mA W$^{-1}$ and the response time was about 139 ms, indicating that the SnSe/In$_2$Se$_3$ vertical heterostructure had great potential to be applied in the broadband photodetectors.
field. Also, this study creates a new avenue for the realization of novel 2D electronic and optoelectronic devices, and more importantly, can develop exciting technologies beyond the reach of the existing materials.

Conflicts of interest
There are no conflicts to declare.

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References


